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## Phosphorus, Sulfur, and Silicon and the Related Elements

Publication details, including instructions for authors and subscription information: http://www.informaworld.com/smpp/title~content=t713618290

## SMALL MOLECULE FIXATION BY A SULFUR-NITROGEN RADICAL

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Online publication date: 12 August 2010

**To cite this Article** Bond, Andrew D. , Clarke, Caroline S. , Haynes, Delia A. , Pascu, Sofia I. and Rawson, Jeremy M.(2004) 'SMALL MOLECULE FIXATION BY A SULFUR-NITROGEN RADICAL', Phosphorus, Sulfur, and Silicon and the Related Elements, 179: 4, 981 - 982

To link to this Article: DOI: 10.1080/10426500490429644 URL: http://dx.doi.org/10.1080/10426500490429644

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Phosphorus, Sulfur, and Silicon, 179:981-982, 2004

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DOI: 10.1080/10426500490429644



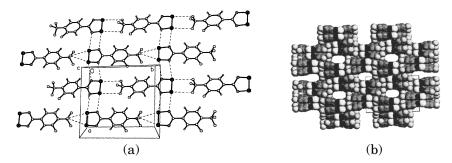
## SMALL MOLECULE FIXATION BY A SULFUR-NITROGEN RADICAL

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Keyword: Dithiadiazoyl radicals

The radical 1,  $CF_3C_6H_3FCNSSN$ , crystallizes with a close-packed layerlike structure (triclinic *P*-1) when sublimed under vacuum (Figure 1a). On sublimation under a partial atmosphere of N2, Ar, CO2, SO2, and CH<sub>4</sub>, a more open structure with a very similar layer-like pattern is formed (orthorhombic Pbcn), but here the layers are buckled such that channels exist along the c-direction (Figure 1b) with the guest molecules accommodated within the channels. In comparison, no inclusion is observed during sublimation in the presence of CFCl<sub>3</sub> and CF<sub>2</sub>Cl<sub>2</sub> whereas sublimation under  $O_2$  generates the dithiatetrazocine, 2. It is thought that the reason behind the inclusion behavior of 1 is that favorable intermolecular interactions  $(S^{\delta+}\cdots N^{\delta-} \text{ and } S^{\delta+}\cdots F^{\delta-})$  are maximized and unfavorable ones  $(F^{\delta-}\cdots F^{\delta-})$  minimized by adopting the more open inclusion structure.

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 $FIGURE\ 1\ \ a)$  Layer-like structure of 1 and b) space-filling diagram of the host-guest structure  $1.N_2.$